

電気学会研究会資料目次

プラズマ研究会

テーマ「プラズマ一般」

〔委員長〕 石井彰三（東工大）
〔副委員長〕 小野 茂（武蔵工大）
〔幹 事〕 小野 靖（東 大）
〔幹事補佐〕 新里卓史（東工大）

日 時 平成 15 年 12 月 15 日（月） 9：00～17：50

場 所 Lunghwa University of Science and Technology 桃園縣龜山 萬壽路一段 300 號 300,
Wan-shou Rd., Sec. 1, Kueishan Taoyuan, Taiwan Tel: (02)82093211 Fax: (02)82094650
キャンパスの詳細はホームページ (<http://www.lhu.edu.tw/>) をご参照下さい。

- PST-03-72 A study on anti-bacterial effect of non-thermal oxygen plasma and bio-medical application
Tetsuya Akitsu, Hiroshi Ohkawa, Masatoshi Ohnishi (University of Yamanashi)
Masao Tsuji (Yamanashi Industrial Technology Center)
Masuhiro Kogoma (University of Sophia) 1
- PST-03-73 High-grade disinfection using high density ozone
Hiroshi Ohkawa, Tetsuya Akitsu, Masatoshi Ohnishi (University of Yamanashi)
Masao Tsuji (Yamanashi Industrial Technology Center) 7
- PST-03-74 APPLICATION OF SECONDARY EMISSION ELECTRON GUN ON
BACTERIAL INACTIVATION
Priya R. Chalise, Mohammad S. Rahman,
Hamid Ghomi, Masato Watanabe, Akitoshi Okino,
Takashi Ano, Makoto Shoda, Eiki Hotta (Tokyo Institute of Technology) 13
- PST-03-75 Application of non-thermal plasma in combination with catalyst for indoor air and
exhaust gas cleaning
Akira Mizuno (Institute for Molecular Science) 17
- PST-03-76 Dilute Trichloroethylene Decomposition in Air by the Non-Thermal Plasma Process

	combined with the Manganese Oxide	
		Tetsuji Oda, SangBo Han (The University of Tokyo) 21
PST-03-77	Optical analysis of a positive pulsed corona discharge	
		Ryo Ono, Tetsuji Oda (The University of Tokyo) 27
PST-03-78	Decomposition of organic contaminants by water surface plasma	
		Masayuki Sato, Tsuyoshi Tokutake, Takayuki Ohshima, Anto Tri Sugiarto (Gunma University) 33
PST-03-79	Development of Compact Ozonizer by Barrier Discharge for High Concentration Ozone Generation	
		Yasunori Ohtsu, Masaharu Toyofuku, Hiroharu Fujita (Saga University) 37
PST-03-80	NO _x TREATMENT USING LOW-ENERGY SECONDARY EMISSION ELECTRON GUN	
		Priya Raj Chalise, Wang Yu, Kamarul Asyikin Mustafa, Masato Watanabe, Akitoshi Okino, Eiki Hotta (Tokyo Institute of Technology) 43
PST-03-81	Filtration Efficiency Improvement of Polypropylene (PP) Filter Using High Pressure DC Corona	
		Tun LWIN, Bong Jo SUNG, Kazunori TAKASHIMA, Shinji KATSURA (Toyohashi University of Technology) Akira MIZUNO (Institute for Molecular Science) 47
PST-03-82	Reduction of Nitric acid into Ammonia using Discharge in Water	
		Youhei Kinoshita, Naoki Okumura, Kazunori Takashima, Shinji Katsura (Toyohashi University of Technology) Akira Mizuno (Institute for Molecular Science) 53
PST-03-83	NO _x Removal Characteristics Using a Dielectric Barrier Type Packed-bed Reactor	
		Toshikazu Ohkubo, Daisuke Ishimaru, Akira Matsuyoshi, Seiji Kanazawa, Yukiharu Nomoto (Oita University) 59
PST-03-84	Decomposition of Dilute VOC in Air by Streamer Corona Discharge with Catalyst	
		Toshikazu Ohkubo, Takuya Yamashita, Shingo Kunitake, Seiji Kanazawa, Yukiharu Nomoto (Oita University) 63
PST-03-85	Decomposition of waste plastics by microwave H ₂ O plasma	
		Toshikazu Yamasaki, Takahiro Otsuki, Shigeru Ono, Shinriki Teii (Musashi Institute of Technology) 67

PST-03-86 Acceleration of NOx Removal by Superimposing Surface Discharge and Photocatalyst
Shunsuke Iwasaki, Masanori Hisa (Musashi Institute of Technology)
Kuniko Urashima (National Institute of Science and Technology Policy)
Yoshiyasu Ehara, Haruo Kishida, Shigeru Ono, Tairo Ito (Musashi Institute of Technology) 71

協 賛 The Japan Chapter on the IEEE Nuclear and Plasma Science Society/Plasma

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PST-03-87 Modifying inner surface of a PET bottle by plasma-based ion implantation
N. Sakudo, H. Endo, R. Yoneda, Y. Ohmura (Kanazawa Institute of Technology)
N. Ikenaga (JST Corporation) 1

PST-03-88 Plasma treatment of polyethylene surface for metallizing by using an atmospheric
pressure corona torch
J. L. Lee, C. M. Liu,
K. Ting, W. K. Cheng (Lunghwa University of Science and Technology)
S. Takizawa, S. Arase, S. Ono, S. Teii (Musashi Institute of Technology) 7

PST-03-89 The modification of polyethylene surface by plasma treatment for metallizing using
a low pressure RF discharge plasma

	J. L. Lee, C. M. Liu, K. Ting, W. K. Cheng (Lunghwa University of Science and Technology) T. Tsuchida, K. Hiramatsu, S. Ono, S. Teii (Musashi Institute of Technology)	13
PST-03-90	INTRODUCTION OF ATMOSPHERIC PRESSURE GLOW PLASMA AND ITS APPLICATION TO THE INDUSTRY Masuhiro Kogoma (Sophia University)	19
PST-03-91	Temporal Variation of Nucleation Density and Crystallinity of Diamond Prepared in Electron Cyclotron Resonance Plasma S. Mizobe, K. Teii, Y. Kouzuma, K. Uchino, K. Muraoka (Kyushu University)	23
PST-03-92	A Low-Pressure Limit of Diamond Chemical-Vapor Deposition Studied by Plasma Diagnostics K. Teii (Kyushu University) M. Hori, T. Goto (Nagoya University)	27
PST-03-93	Plasma oxidation process of silicon surfaces investigated by infrared spectroscopy Masanori Shinohara, Teruaki Katagiri, Keitaro Iwatsuji, Yoshinobu Matsuda (Nagasaki University) Yasuo Kimura, Michio Niwano (Tohoku University) Hiroshi Fujiyama (Nagasaki University)	33
PST-03-94	X-ray Diffraction Studies of Magnesium Oxide Thin Films Deposited by Ionized Reactive Sputtering Y. Matsuda, Y. Koyama, M. Iwaya, M. Shinohara, H. Fujiyama (Nagasaki University)	37
PST-03-95	Electrical Properties in $\text{Si}_{1-x}\text{Ge}_x$ Thin Films Prepared by Pulsed Ion-Beam Evaporation M. Hirai, R. Iwashita, T. Suzuki, H. Suematsu, T. Arikado, K. Yatsui (Nagaoka University of Technology)	43
PST-03-96	Reduction of Oxygen Content in Ti-Fe Thin Films Prepared by Pulsed Laser Deposition Shuntaro Suzuki, Satoko Ogata, Makoto Hirai, Tsuneo Suzuki, Hisayuki Suematsu, Weihua Jiang, Kiyoshi Yatsui (Nagaoka University of Technology)	47
PST-03-97	Preparation of Passivated Cu Nanosized Powders by Pulsed Wire Discharge K. Murai, Y. Tokoi, K. Suwa, H. Suematsu, W. Jiang, K. Yatsui (Nagaoka University of Technology)	51
PST-03-98	Synthesis of Single-Walled Carbon Nanotubes in Various Gas by Pulsed Wire Discharge Ryouta Kobayashi, Seigo Nishimura, Hisayuki Suematsu, Weihua Jiang, Kiyoshi Yatsui (Nagaoka University of Technology)	57

PST-03-99	Plasma Properties of ICP Etching using SF ₆ -O ₂ Gas Mixture and Their Relationship to Etching Characteristics	H. Tanaka, Y. Ichikawa (Fuji Electric Device Technology) S. Wakimoto, A. Yajima, K. Mochizuki, Y. Nagayasu, (Fuji Electric Advanced Technology) S. Matsumura (Musashi Institute of Technology)	63
PST-03-100	DEPOSITION OF MULTI-LAYER FILMS OF HEXAFLUOROPROPENE-ETHYLENE COMPOSITE POLYMER WITH JET-TYPE PLASMA REACTOR AT ATMOSPHERIC PRESSURE	Kunihito Tanaka, Masuhiro Kogoma (Sophia University)	67
PST-03-101	Spatial profile control of electron density and plasma space potential and generations of high-quality diamond films in the 2.45GHz surface wave type plasma processing devices	Makoto Katsurai, Takayuki Toba, Jaeho Kim (University of Tokyo).....	71
協 賛	The Japan Chapter on the IEEE Nuclear and Plasma Science Society/Plasma		

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PST-03-102 New Applications of Pulsed Power Technology to Materials Science

	Kiyoshi YATSUI, Hisayuki SUEMATSU, Weihua JIANG (Nagaoka University of Technology)	1
PST-03-103	Magnetic Energy Recovery Type Marx-Generator for High Repetition Plasma Discharge Takanori Isobe, Taku Takaku, Jun Narushima, Shunji Tsuji-Iio, Ryuichi Shimada (Tokyo Institute of Technology)	5
PST-03-104	Oxidation Resistance in Cr(N,O) Thin Films Prepared by Pulsed Laser Deposition Jun Inoue, Hiroki Asami, Makoto Hirai, Tsuneo Suzuki, Hisayuki Suematsu, Weihua Jiang, Kiyoshi Yatsui (Nagaoka University of Technology)	9
PST-03-105	HIGH POWER MICROWAVE GENERATION BY VIRTUAL CATHODE OSCILLATOR W. Jiang, N. Shimada, K. Kanbara, K. Yatsui (Nagaoka University of Technology)	15
PST-03-106	Development of Repetitive Pulsed High-Current Generator for EUV Applications Nobuaki Oshima, Tomoyuki Yokoo, Weihua Jiang, Kiyoshi Yatsui (Nagaoka University of Technology) Kazuya Shimada, Akira Tokuchi (Nichicon Corporation)	19
PST-03-107	{ 欠 番 }	
PST-03-108	A micro-plasma created from a powder particle by pulsed discharges Shozo Ishii, Takuma Yokoyama, Kazuya Takano, Shinji Ibuka, Koichi Yasuoka (Tokyo Institute of Technology)	23
PST-03-109	Dependence of Gas Temperature of Oxygen Plasma on Discharge Conditions K. Naoi, T. Sakamoto, H. Matsuura, H. Akatsuka (Tokyo Institute of Technology)	27
PST-03-110	Acceleration Phenomenon of Helium Arc Jet through a Magnetic Nozzle T. Kanuma, M. Matsuzaki, H. Matsuura, H. Akatsuka (Tokyo Institute of Technology)	33
PST-03-111	Characteristics of Molecular- and Rare-Gas Plasmas Produced by Helicon Wave in Low Magnetic Fields Genta Sato, Wataru Oohara, Rikizo Hatakeyama (Tohoku University) Kayoko Fujimoto (Japan Science and Technology Corporation)	39
PST-03-112	Application of high- T_c superconducting bulk magnets to the confinement of weakly ionized plasma Hidenori Matsuzawa, Kazuya Ohishi, Kazuhiro Ishikawa, Keigo Itou, Tomonori Morita (University of Yamanashi) Masaaki Yoshikawa (IMRA Material R & D)	

	Hiroshi Ikuta, Uichiro Mizutani (Nagoya University)	45
PST-03-113	Energy Distribution Functions of Ions Impacting on DC and RF Biased Substrate in a New Type ECR Plasma with Ring Shaped Permanent Magnets Yasunori Ohtsu, Hiroharu Fujita (Saga University)	49
PST-03-114	GENERATION OF HIGH-CURRENT GLOW DISCHARGE IN NITROGEN Koichi Takaki, Masato Hosokawa, Takashi Sasaki, Seiji Mukaigawa, Tamiya Fujiwara (Iwate University)	55
PST-03-115	Oxygen Radical Density Measurement in O ₂ -N ₂ mixture gas plasma by means of thin platinum wire probe N. Haraki, S. Ono, S. Teii (Musashi Institute of Technology)	61
PST-03-116	Space Potential Control in 2.45GHz Surface Wave Excited Plasmas using Superimposed DC Bias Voltage Jaeho Kim, Makoto Katsurai (University of Tokyo)	67
協 賛	The Japan Chapter on the IEEE Nuclear and Plasma Science Society/Plasma	